

GaAs-IR-Lumineszenzdiode
GaAs Infrared Emitter
Lead (Pb) Free Product - RoHS Compliant

LD 242



Wesentliche Merkmale

- Hergestellt im Schmelzepitaxieverfahren
- Kathode galvanisch mit dem Gehäuseboden verbunden
- Hohe Zuverlässigkeit
- Großer Öffnungskegel
- Gehäusegleich mit BP 103, BPX 63, SFH 464, SFH 483
- Anwendungsklasse nach DIN 40 040 GQC

Anwendungen

- Lichtschranken für Gleich- und Wechsellichtbetrieb
- Sensorik
- Lichtgitter

Features

- Fabricated in a liquid phase epitaxy process
- Cathode is electrically connected to the case
- High reliability
- Wide beam
- Same package as BP 103, BPX 63, SFH 464, SFH 483
- DIN humidity category in acc. with DIN 40 040 GQG

Applications

- Photointerrupters
- Sensor technology
- Light curtains

Typ Type	Bestellnummer Ordering Code	Strahlstärkegruppierung ¹⁾ ($I_F = 100 \text{ mA}$, $t_p = 20 \text{ ms}$) Radiant Intensity Grouping ¹⁾ I_e (mW/sr)
LD 242-2/3	Q62703Q4749	> 4.0
LD 242 E7800	Q62703Q3509	1 - 3.2

¹⁾ gemessen bei einem Raumwinkel $\Omega = 0.01 \text{ sr}$
 measured at a solid angle of $\Omega = 0.01 \text{ sr}$

Grenzwerte ($T_A = 25\text{ °C}$)**Maximum Ratings**

Bezeichnung Parameter	Symbol Symbol	Wert Value	Einheit Unit
Betriebs- und Lagertemperatur Operating and storage temperature range	$T_{op}; T_{stg}$	- 40 ... + 80	°C
Sperrspannung Reverse voltage	V_R	5	V
Durchlassstrom Forward current	I_F	300	mA
Stoßstrom, $\tau \leq 10\ \mu\text{s}$, $D = 0$ Surge current	I_{FSM}	3	A
Verlustleistung Power dissipation	P_{tot}	470	mW
Wärmewiderstand Thermal resistance	R_{thJA} R_{thJC}	450 160	K/W K/W

Kennwerte ($T_A = 25\text{ °C}$)**Characteristics**

Bezeichnung Parameter	Symbol Symbol	Wert Value	Einheit Unit
Wellenlänge der Strahlung Wavelength at peak emission $I_F = 100\text{ mA}$, $t_p = 20\text{ ms}$	λ_{peak}	950	nm
Spektrale Bandbreite bei 50% von I_{max} Spectral bandwidth at 50% of I_{max} $I_F = 100\text{ mA}$, $t_p = 20\text{ ms}$	$\Delta\lambda$	55	nm
Abstrahlwinkel Half angle	φ	± 40	Grad deg.
Aktive Chipfläche Active chip area	A	0.25	mm ²
Abmessungen der aktiven Chipfläche Dimension of the active chip area	$L \times B$ $L \times W$	0.5×0.5	mm ²
Abstand Chipoberfläche bis Linsenscheitel Distance chip surface to lens top	H	0.3 ... 0.7	mm

Kennwerte ($T_A = 25\text{ °C}$)

Characteristics (cont'd)

Bezeichnung Parameter	Symbol Symbol	Wert Value	Einheit Unit
Schaltzeiten, I_e von 10% auf 90% und von 90% auf 10%, bei $I_F = 100\text{ mA}$, $R_L = 50\ \Omega$ Switching times, I_e from 10% to 90% and from 90% to 10%, $I_F = 100\text{ mA}$, $R_L = 50\ \Omega$	t_r, t_f	1	μs
Kapazität Capacitance $V_R = 0\text{ V}$	C_o	40	pF
Durchlassspannung Forward voltage $I_F = 100\text{ mA}$ $I_F = 1\text{ A}$, $t_p = 100\ \mu\text{s}$	V_F V_F	1.3 (≤ 1.5) 1.9 (≤ 2.5)	V V
Sperrstrom, $V_R = 5\text{ V}$ Reverse current	I_R	0.01 (≤ 1)	μA
Gesamtstrahlungsfluss Total radiant flux $I_F = 100\text{ mA}$, $t_p = 20\text{ ms}$	Φ_e	16	mW
Temperaturkoeffizient von I_e bzw. Φ_e , $I_F = 100\text{ mA}$ Temperature coefficient of I_e or Φ_e , $I_F = 100\text{ mA}$	TC_I	- 0.55	%/K
Temperaturkoeffizient von V_F , $I_F = 100\text{ mA}$ Temperature coefficient of V_F , $I_F = 100\text{ mA}$	TC_V	- 1.5	mV/K
Temperaturkoeffizient von λ_{peak} , $I_F = 100\text{ mA}$ Temperature coefficient of λ_{peak} , $I_F = 100\text{ mA}$	TC_λ	0.3	nm/K

Gruppierung der Strahlstärke I_e in Achsrichtunggemessen bei einem Raumwinkel $\Omega = 0.01$ sr**Grouping of Radiant Intensity I_e in Axial Direction**measured at a solid angle of $\Omega = 0.01$ sr

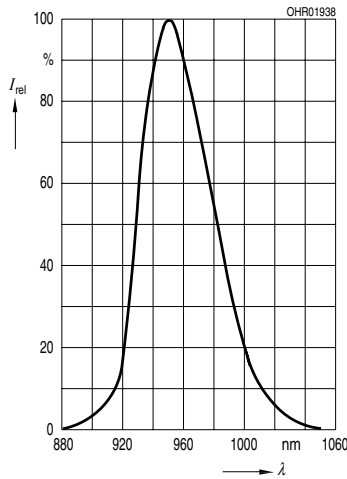
Bezeichnung Parameter	Symbol	Werte Values			Einheit Unit
		LD 242-2	LD 242-3	LD 242 7800 ¹⁾	
Strahlstärke Radiant intensity					
$I_F = 100$ mA, $t_p = 20$ ms	I_e	4 ... 8	> 6.3	1 ... 3.2	mW/sr
$I_F = 1$ A, $t_p = 100$ μ s	$I_{e \text{ typ.}}$	50	75	–	mW/sr

¹⁾ Die Messung der Strahlstärke und des Halbwinkels erfolgt mit einer Lochblende vor dem Bauteil (Durchmesser der Lochblende: 1,1 mm; Abstand Lochblende zu Gehäuserückseite: 4,0 mm). Dadurch wird sichergestellt, dass bei der Strahlstärkemessung nur diejenige Strahlung in Achsrichtung bewertet wird, die direkt von der Chipoberfläche austritt. Von der Bodenplatte reflektierte Strahlung (vagabundierende Strahlung) wird dagegen nicht bewertet. Diese Reflexionen sind besonders bei Abbildungen der Chipoberfläche über Zusatzoptiken störend (z.B. Lichtschranken großer Reichweite). In der Anwendung werden im allgemeinen diese Reflexionen ebenfalls durch Blenden unterdrückt. Durch dieses der Anwendung entsprechende Messverfahren ergibt sich für die Anwender eine besser verwertbare Größe. Diese Lochblendenmessung ist gekennzeichnet durch den Eintrag „E 7800“, der an die Typenbezeichnung angehängt ist.

¹⁾ An aperture is used in front of the component for measurement of the radiant intensity and the half angle (diameter of the aperture: 1.1 mm; distance of aperture to case back side: 4.0 mm). This ensures that solely the radiation in axial direction emitting directly from the chip surface will be evaluated during measurement of the radiant intensity. Radiation reflected by the bottom plate (stray radiation) will not be evaluated. These reflections impair the projection of the chip surface by additional optics (e.g. long-range light reflection switches). In respect of the application of the component, these reflections are generally suppressed by apertures as well. This measuring procedure corresponding with the application provides more useful values. This aperture measurement is denoted by “E 7800” added to the type designation.

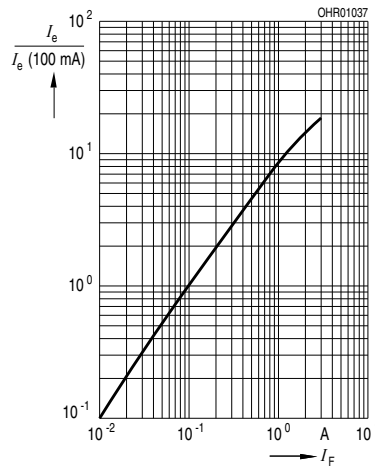
Relative Spectral Emission

$I_{rel} = f(\lambda)$



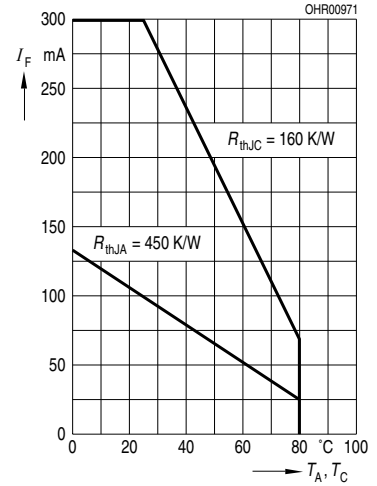
Radiant Intensity $\frac{I_e}{I_e \text{ 100 mA}} = f(I_F)$

Single pulse, $t_p = 20 \mu\text{s}$



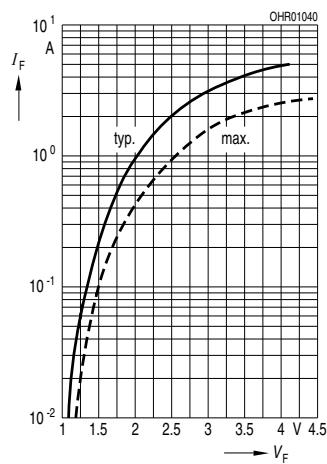
Max. Permissible Forward Current

$I_F = f(T_A)$



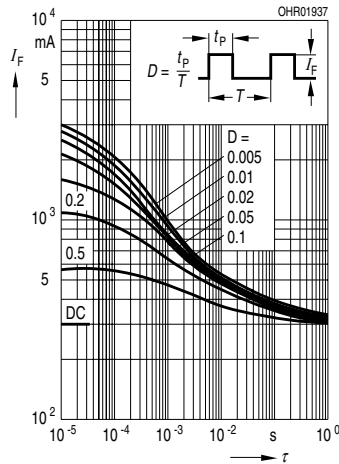
Forward Current

$I_F = f(V_E)$



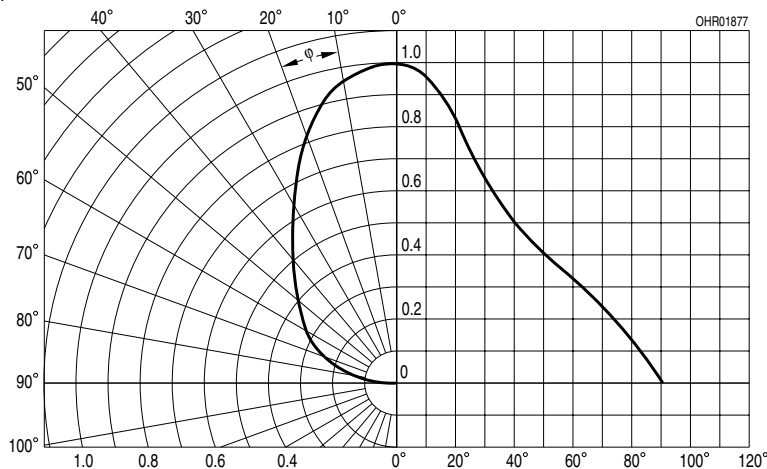
Permissible Pulse Handling Capability

$I_F = f(\tau)$, $T_C = 25 \text{ }^\circ\text{C}$, duty cycle $D = \text{parameter}$

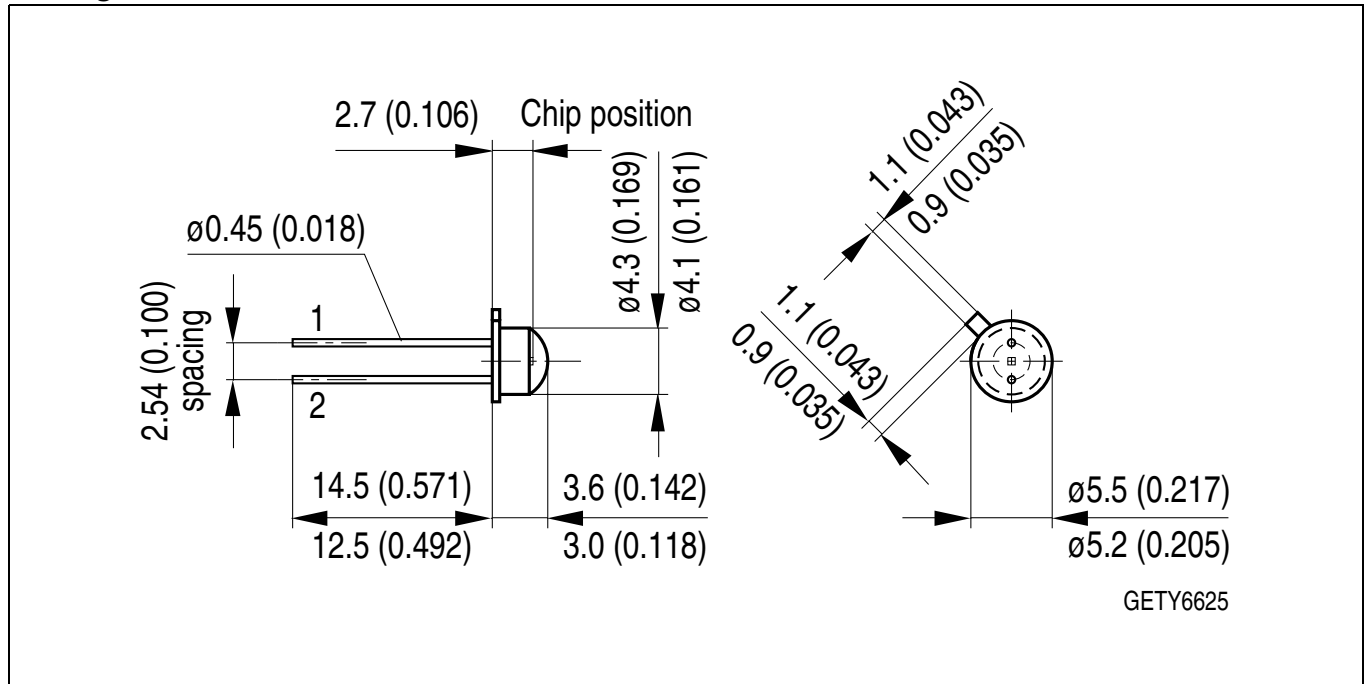


Radiation Characteristics

$I_{rel} = f(\varphi)$



Maßzeichnung
Package Outlines



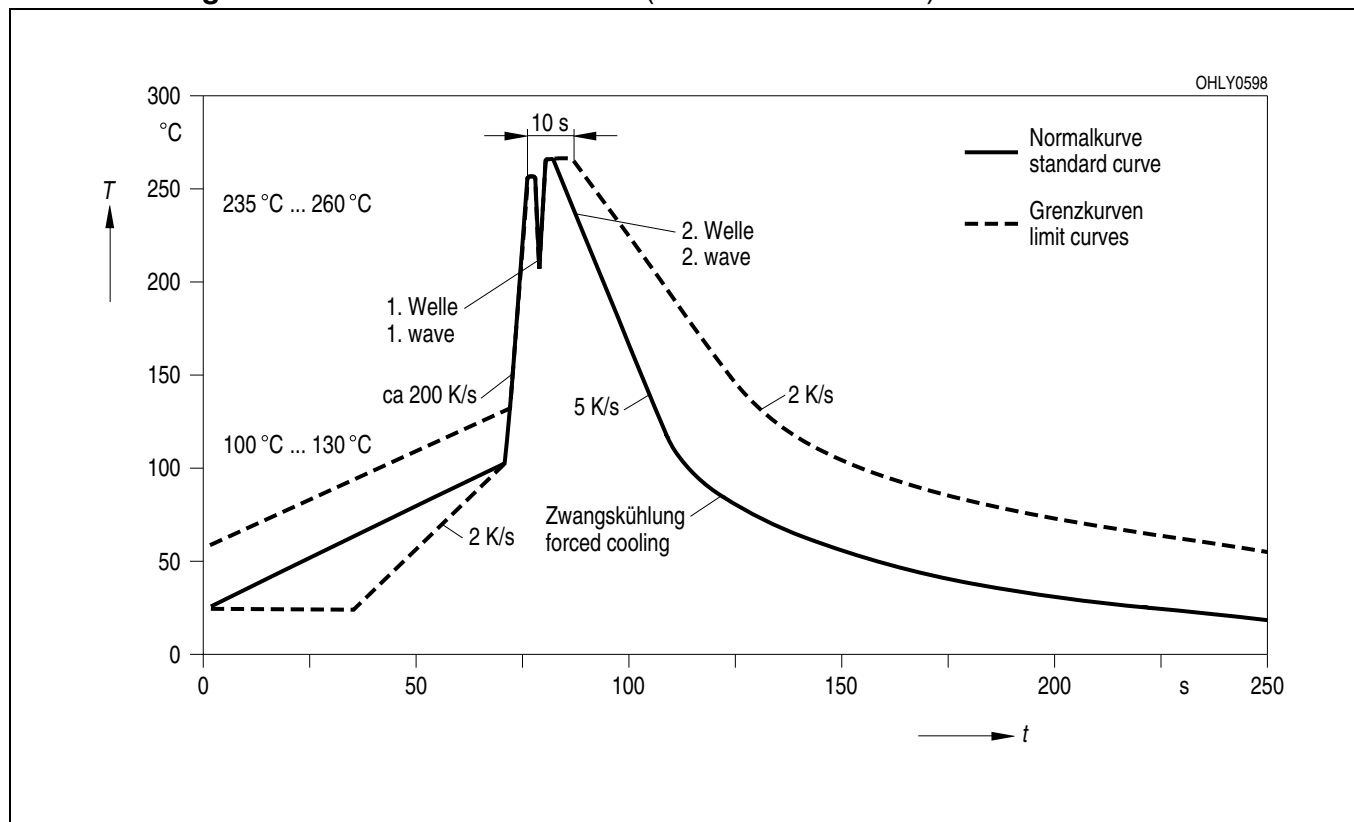
Maße in mm (inch) / Dimensions in mm (inch).

Gehäuse Package	18 A3 DIN 41876 (TO-18), klares Epoxy-Gießharz 18 A3 DIN 41876 (TO-18), transparent epoxy resin
Anschlussbelegung pin configuration	1 = Anode/ anode 2 = Kathode/ cathode

Lötbedingungen
Soldering Conditions
Wellenlöten (TTW)
TTW Soldering

(nach CECC 00802)

(acc. to CECC 00802)



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